

D 263[®] T eco

The gold standard in imaging & sensing

This thin borosilicate glass is the gold standard in imaging and sensing fields. Thanks to unique down-draw technologies, D 263[®] T eco has a fire-polished surface, high optical precision and geometrical accuracy. It is available in a variety of thicknesses from 1.1 mm down to 0.03 mm.



High optical transmittance



Wide thickness range





Tight geometrical properties





High temperature stability

Applications

All-round technical excellence makes D 263[®] T eco a highly valued glass in many applications across different fields, setting gold standards in these markets.

D 263[®] T eco can be used for:

- IR cut filter
- Optical low pass filter (OLPF) substrate
- · Wafer-level optics
- Micro-lens arrays (MLA)
- Diffractive optical elements (DOE)
- Diffusors
- Sensor cover
- Carrier wafer



Automotive



Consumer electronics



Semiconductors



Smart home

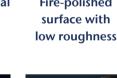


Industry





Fire-polished surface with low roughness





Optics

SCHOTT D 263[®] T eco

Outstanding and adaptable technical advantages

High optical transmittance

The unique composition of D 263[®] T eco and its top-quality blend of raw materials enables a high level of high optical transmittance in the UV to NIR range. A colorless appearance also helps to deliver optimum image quality, without unwanted colorization effects regardless of application.

High chemical stability

SCHOTT D 263[®] T eco performs consistently well in demanding conditions. Its high chemical resistance makes it particularly resilient in the consumer electronics, semiconductor, automotive and optical fields.

A wide range thicknesses

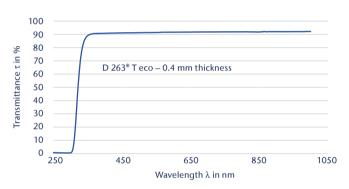
While D 263[®] T eco is available in a wide variety of thicknesses (from 0.03 mm to 1.1 mm), the geometrical tolerances of the glass remain consistently tight, with guaranteed quality for sheet, cut-to-size substrates and wafer.

Tight geometrical properties

Mechanical properties

Density p

Tight thickness tolerance, low TTV and warp enables high quality wafer level optics.



Optical properties		
Refractive index n _D	1.5230	
Luminous transmittance τ_{vD65} (d = 0.30 mm)	91.7%	

Chemical properties			
Hydrolytic resistance	DIN ISO 719	HGB 1	
Acid resistance	DIN 12116	S 3	
Alkali resistance	DIN ISO 695	A 2	

Young's modulus E	kN/mm ²	72.9	
Poisson's ratio µ		0.21	
Knoop hardness	HK 0.1/20	470	
Vickers hardness	HV 0.2/25	510	
Chemical toughening		possible	
Electrical properties			
	1 GHz	6.4	
Electrical properties Dielectric constant ε_r	1 GHz 5 GHz	6.4 6.3	
		••••	

g/cm³

2.51

Thermal properties	
Coefficient of thermal expansion α (20 °C; 300 °C)	7.2 · 10 ⁻⁶ K ⁻¹
Transformation temperature T _g	557°C

Geometrical properties	Sheet			Wafer	
Formats*	Min. Length x Width [mm]	440 x 360		Rectangular min.	50 x 50
	Max. Length x Width [mm]	510 x 430		Rectangular max.	300 x 300
				Round min.	50 (2 inch)
				Round max.	300 (12 inch)
Thickness range	Min. [mm]		0.03		
	Max. [mm]		1.10		
Surface roughness			< 1 nm RM	S	

* Customized formats are available upon request.

SCHOTT glass made of ideas

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